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***In-situ* Deposition of Three-Dimensional Graphene on Selective Laser Melted Copper Scaffolds for High Performance Applications**

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Abstract: Currently, three-dimensional graphene (3DG) fabrication was restricted by the complicated process, strict chemical reactions as well as structural accuracy. Herein we creatively propose a bottom-up strategy that leverages selective laser melting (SLM) technique to manufacture a three-dimensional (3D) porous copper template. Graphene was then *in-situ* grown via chemical vapor deposition (CVD) on the obtained template, forming 3DG composites. A combination of conventional graphene growth via CVD technique with SLM fabricated scaffold templates enabled an accurate design and regulation of 3DG from macro-structure (unit type, porosity, aperture) to micro-structure (texture, surface quality) through an elaborately manipulated porous copper scaffold. The 3DG/copper scaffold could achieve around 88 % and 27 % enhancement in electromagnetic interference (EMI) shielding and thermal diffusion, respectively. Particularly, the highest EMI shielding efficiency (*SE*) can reach up to 47.8 dB at 2.7 GHz

and exhibit an average SE of 32.3 dB at the range of 2-18 GHz. The synergistic shielding mechanisms accounted for the improvement derived from the use of hybrid composite materials and precise architecture of the SLM porous structure.

Keywords: *Three-dimensional graphene, copper porous scaffold, selective laser melting, chemical vapor deposition, electromagnetic interference shielding*

1. Introduction

Graphene, consisting of sp^2 hybridized carbon atoms, has gained wide popularity owing to its advantageous performance, such as high surface area ($2630 \text{ m}^2 \text{ g}^{-1}$) [1], excellent intrinsic carrier mobility ($2 \times 10^5 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$) and superior thermal conductivity ($\sim 5000 \text{ W m}^{-1} \text{ K}^{-1}$) [2]. However, the strong π - π interaction between two dimensional (2D) single-layer graphene sheet is prone to aggregation, because graphene suffers from shape instability as it tends to roll, scroll, wrinkle, fold - up unless it is constrained onto a solid surface [3]. Aforementioned features lead to significantly reduced effective properties and a gap between theoretical promises and practical applications. Confronting with these problems, three-dimensional graphene (3DG) shows better promise in high porosity ($\sim 99.7 \%$), low specific gravity ($\sim 0.6 \text{ mg m}^{-2}$) [4] accompanied with higher specific surface areas as well as loading capacity, faster electronic conduction and mass transfer even superior to that of two-dimensional graphene (2DG), extending applications in catalysis [5], energy storage [6, 7], sensors [4], electromagnetic interference (EMI) shielding [8] and so on.

Various types of methods regarding 3DG preparation have been developed, including freeze drying [9], hydrothermal reaction [10], self-assembly [11], de-alloy [12] and so on. However, the aforementioned methods still facing some challenges. For example, freeze drying and hydrothermal reaction suffer from

poor control on morphologies and connections of graphene layers [13]. Self-assembly method requires long process time (several days) owing to dialysis and lyophilization [14]. De-alloy method shows limitation on controlling the types and quantities of pores due to the selective dissolution of composition [15]. Most approaches mentioned above are hardly to construct desirable structure to satisfy the requirement of functional design, while template-directed CVD method shows this superiority, along with the advantages of large-area and high-quality graphene [16]. By this method, when temperature cooled down, carbon is soluble and the graphene form on the metal substrate which acts as a reaction catalyst. The microscopic characteristics (i.e., composition and microstructure), exert a determined influence on the final microstructure (i.e., layer thickness, defects) of the prepared 3DG. Besides, the generated 3DG will inherit the macro properties from the metal template (i.e., porosity, pore size, surface quality). However, most of the porous metal templates prepared by conventional methods have difficulty precisely regulating porosity, for instance, the commercial Ni foam generally changes the porosity by roughly controlled foaming agent content, the subsequently obtained 3DG shows poor control of macroscopic and microscopic features for specific functional design [17, 18]. Hence, it is of necessity to develop metal templates, which can be precisely manipulated from macro to micro aspects to achieve 3DG with tunable structures and stable performances [19].

Selective laser melting (SLM), as an innovative additive manufacturing (AM) technology, is particularly designed for the fabrication of sophisticated and/or precise three-dimensional (3D) metal templates with great advantages of complexity in design, efficiency in production and flexibility of *in-situ* manufacturing capability. To date, numerous researches have reported SLM porous structures of Ti alloys [20], stainless alloys [21], and Ni alloys [22]. Cu is the most widely used foil for large-area graphene synthesized in

state-of-the-art research and industrial areas. Compared with Ni or other substrate, copper is regarded as a more desirable substrate for graphene growth via CVD due to the lower carbon saturation level (<0.001 at.%) and growth process self-limiting of copper, which tend to generate higher quality single layered graphene with larger areas [23]. While Ni has a higher carbon solubility (>0.1 at. %) [17], thick graphene films tend to form because of excessive carbon precipitation [24]. However, research in SLM of pure copper is still in its infancy because of insufficient heating for powders melting derived from its intrinsic high thermal conductivity and reflectivity towards common laser wavelength (1000-1100 nm). Fabrication of precise and condense copper scaffolds via SLM is still facing many challenges [25].

To overcome above limitations, we here for the first time propose a feasible bottom-up approach to produce 3DG/copper (3DG/Cu) structures via SLM simultaneously in combination with CVD growth of graphene. A well-designed gyroid-type porous copper template was initially investigated via SLM from microstructural evolution to macroscopic performance, especially with respect to anisotropy and heterogeneity. Then *in-situ* graphene growth on this porous copper template via CVD method resulted in the 3DG/Cu structure. By combining excellent electrical ($5.7 \times 10^7 \text{ S m}^{-1}$) and thermal conductivities ($398 \text{ W m}^{-1} \text{ K}^{-1}$) with the good mechanical properties of copper, 3DG/Cu not only presents excellent functionalities in the electrical and thermal field, but also displays lightweight and robust design, preventing 3DG from collapsing through the aid of the metal template. The synergistic effects from multi-materials and porous structures enable great improvements in EMI and thermal management performances of the lightweight 3DG/Cu scaffold. Specifically, the 3DG/Cu composite structure displays a multiple shielding mechanism network with strong microwave attenuation from reflection and absorption shielding efficiency (*SE*). The regulation of the SLM porous template via precise design of

architectures for optimized properties is comprehensively discussed in this work.

2. Experimental

2.1 Materials

The pure gas atomized copper powder was micron-size and most of the particles exhibit a spherical shape, which can increase the fluidity and packing density compared to polyhedral ones [26]. The average particle size was $18.856 \pm 15 \mu\text{m}$, smaller than the laser spot ($30 \mu\text{m}$) (**Fig. S1**). The chemical composition of the initial copper powder is listed in **Table S1**.

2.2 Preparation of Cu components via SLM

To approach quality copper samples, a thorough parameter investigation from single line to cubic formation was conducted using a SISMA MYSINT100 system with an Nd:YAG fiber laser (wavelength of 1060 nm, maximum output laser power of 200 W, laser spot size of $30 \mu\text{m}$) under high purity nitrogen gas atmosphere (residual oxygen concentration $< 0.5 \text{ vol.}\%$), protecting the powder from oxidation. It is worthy of knowing that the used laser spot is much smaller than the common laser ($100 \mu\text{m}$), which ensure the fine architectures.

Samples of rectangular contour ($1.0 \times 2.5 \text{ mm}$) and cubic samples ($8 \times 8 \times 8 \text{ mm}^3$) were fabricated for single track and bulk experience, respectively. The processing parameters window for the cubic samples (**Table S2**) and the laser scanning strategy was chessboard with each layer divided into 4 squares, and with the scanning direction inside the square perpendicular to that of the adjacent square. Based on preliminary research, the laser power and layer thickness were fixed at 180 W and 0.02 mm to ensure formability. Different volumetric laser energy densities are investigated (**Eq. 1**).

$$E = \frac{P}{v \times h \times t} \quad (1)$$

Where E , P , v , h and t represent the volumetric laser energy density (J/mm^3), laser powder (W), scanning speed (mm/s), hatch distance (mm) and layer thickness (mm), respectively.

Specific size samples with different orientations (parallel to the x- and z-axis) labeled as EC-x, EC-z ($2 \times 2 \times 20 \text{ mm}^3$), TC-x, TC-z ($2 \times 10 \times 10 \text{ mm}^3$) were for electrical and thermal conductivity test according to ASTM B193-2002 and ASTM E1461-2013, respectively. The Gyroid-type porous cylinder specimens ($\Phi = 7 \times 3.05 \times 2 \text{ mm}$) were fabricated under the optimal processing parameters for cubic samples according to ASTM ES7-83 (**Table S2**). Based on previous study, 26 PPI and 17 PPI scaffolds were prepared, with pore radius of $250 \mu\text{m}$ and $450 \mu\text{m}$, respectively.

2.3 Synthesis of 3DG/Cu Porous Scaffold via CVD

3DG/Cu scaffolds were manufactured using the following procedures (**Fig. 1**). The SLM copper scaffold template was placed into the quartz tube of the CVD system (G-CVD-5, China). The CVD process can be found in previous report [24]. For comparison, a group of copper scaffolds processed heat treatment (HT) under the same temperature (For more details please refer to Supporting Information **Table S3**).

2.4 Characterization Techniques

The starting powder was characterized by inductively coupled plasma-mass spectrometry (ICP-MS, Agilent 7700, US). The size distribution of the powder was analyzed by a particle size analyzer (Runzhi Rise-2002, China). The surface morphology and microstructure were observed under an optical microscopy (OM, Leica A205, Germany) and scanning electron microscope with an energy dispersive spectroscopy (SEM-EDS, Hitachi-Su8010, Japan). Before metallographic observation, the rectangular contour samples were processed polishing and etchant (in a mixed solution of 5 g FeCl_3 , 5 ml HCl and $100 \text{ ml distilled H}_2\text{O}$ for 10 s) according to a standard metallographic procedure. The density of the cubic

samples was measured by the Archimedes method and presented as a relative density to the copper powder (8.9 g/cm³). Phase structure was tested using X-ray diffraction (XRD, Bruker D8 Advance, Germany) with Cu-K α radiation at 40 KV and 40 mA in the range $2\theta = 20^\circ\text{--}90^\circ$, using a step size of 0.02°. The Vickers hardness measurements were carried out on both horizontal and vertical planes of the specimens at a load of 3 N (HV3) and a dwell time of 10 sec. Ten indentations points were conducted from one edge to the opposite across the surface of the samples and average values were reported. The electrical resistivity measurement (ZEM-3) met ASTM B193-2002 requirements with a sample size of $2 \times 2 \times 20 \text{ mm}^3$ from both horizontal and vertical orientations. The thermal diffusivity measurement on the cubic ($2 \times 10 \times 10 \text{ mm}^3$) and porous structure ($5 \times 10 \times 10 \text{ mm}^3$) followed ASTM E1461-2013 with a sample size of the aforementioned two orientations using the LFA (Laser flash method, Netzsch LFA457, Germany). Raman spectroscopy (SENTERRA, Bruker, Germany) was used to characterize the 3DG/Cu scaffold with an excitation wavelength of 514 nm. The S parameters (S_{11} and S_{21}) were measured with a vector network analyzer (VNA, Agilent PNA-N5244A, US) using the coaxial method in 2-18 GHz. The values of SE_{total} , SE absorption, and SE reflection were determined as **Eq. 2-5** in the Supporting Information.

3. Results and Discussion

3.1 Formation of SLM Copper

3.1.1 SLM Manufacturing of Copper under Different Line Energy Densities

The most effective parameters (laser power and scanning speed) were preliminarily investigated via single track experience. Different types of single tracks were observed and the processing window could be divided into four distinguishing zones (**Fig. 2**) based on the melting tracks quality, including 30 %

weak sintering zone (A), 26.7 % unstable melting zone (B), 16.7 % continuous track zone (C) and 26.7 % excessive melting zone (D). Different zones represent diverse line energy density, LED (J/m) [27] (Eq. 6, please refer to SI). The selected laser device and processing optimization proved to overcome the challenges of high reflectivity and thermal conductivity of copper. The less continuous track area also indicated the forming difficulty with limited process parameters. In zone A, scanning track was difficult to form because the line energy density was insufficient. In zone B, the powder could not form stable width tracks with lots of unmolten powder sticking to the surface owing to energy deficiency. The melt flow of the molten pool becomes stable with sufficient depth of penetration into the former layer and as a result, a relatively smooth track was obtained with a minimum input LED of 400 J/m (zone C). When an excessive LED (> 800 J/m) is applied, a roughly 130 μm wide track occurred and micro-cracks also appeared (zone D), which were caused by high residual stresses resulting from the excess heat accumulation associated with the high power as well as low scanning speed [28].

3.1.2 Formation of Anisotropic Microstructure under Different Volumetric Energy Density

The main phase α -copper could be clearly characterized in all XRD patterns by the (111) and (200) reflections diffracted at $2\theta = 43.32^\circ$ and $2\theta = 50.45^\circ$, respectively (Fig. 3), and the (111) direction was much prevailing. The as-built copper specimens presented similar XRD patterns to the starting powder and the distinguishing differences in the broadening breadth of peaks which implied grain refinement in the SLM process. In addition, the diffraction peaks of SLM samples shifted to higher diffraction angles, indicating an enhancement of residual stress in the as-built samples due to the high cooling rate [29].

The morphology of the molten pool was characterized on the vertical section of the SLM pure copper part to analyze defect mechanisms of samples with varying energy input. Three main types of defects were

observed: (i) inter-layer voids, (ii) non-melted powder, and (iii) gas pores. At excessive input energy of 3000 J/mm^3 (**Fig. 4a**), the melt pool was as wide as $180 \mu\text{m}$, six times wider than for the low energy one (**Fig. 4d**). The droplet spatters could be seen due to the Marangoni convection [30] causing dramatic fluctuation and evaporation in the molten pool. These spatters later became inter-layer inclusions which hindered the powder spreading processing and finally leading to voids inside the part. With the input energy further decreasing and settling at 857 J/mm^3 , sound parts with few microspores were obtained and the molten pool size diminished as indicated by the yellow dash (**Fig. 4b**). Under these conditions, the pure copper part achieved highly densification up to 96.2 % with good metallurgical bonding. However, with decreasing input energy by enhancing the hatch distance, irregular pores and non-melted area were dispersed in the neighboring layers. The heat in the molten pool transmitted fast to the surrounding area due to the high thermal conductivity of pure copper ($398 \text{ W m}^{-1} \text{ K}^{-1}$), and thus insufficient input energy was unable to melt the raw materials thoroughly (**Fig. 4c**). Gas holes could also be found in this case, which failed to escape from the molten pool and were trapped by the Marangoni convection. Besides, the detected phosphorous content in the raw materials may also lead to gas holes and the oxides may act as nucleation sites for pore formation during the SLM process [31]. In contrast, at lower input energy of 128 J/mm^3 , pockets of non-melted powder and irregular voids appeared across the whole sample with narrow-shallow fish scale-like voids, accounting for 88.6% of the relative density (**Fig. 4d**).

The evolution of microstructures in the SLM process were shown to understand the relevant changes (**Fig. 5**). The typical epitaxial columnar grains parallel the building direction were formed on the vertical section, which were mainly attributed to the anisotropy feature derived from the temperature gradient. The temperature gradient vector at the solid-liquid interface is from the center of the molten pool to the

bottom owing to the vertically downwards heat conduction path to the substrate, which facilitates the growth of columnar microstructures [32]. The extremely high thermal conductivity of pure copper in solid state intensifies the heat flow along the building direction. Similar to the work by Wang et al. [33], the equiaxed cell became the dominant structure in the horizontal plane, resulting from heat radiation through the surrounding powder bed and environment. The average grain size in the horizontal section of the copper SLM samples was less than 100 μm , much finer than that of casted reference samples (400 μm), corresponding to the significantly different cooling rate between the SLM samples (10^5 – 10^8 K/s) and the cast samples (1 K/s) [34].

3.2 Effect of Anisotropic Microstructure on Properties of SLM Copper

3.2.1 Effect of Anisotropic Microstructure on Vickers Microhardness

A Vickers hardness profiles in **Fig. 6** is used to assess the possible effect of different energy densities and orientations on microhardness. The average Vickers hardness initially increased to the peak value of 92.9 HV at 857 J/mm^3 and then decreased with reduced input energy. The excessive energy led to coarser grains as well as more serious spattering behavior, which were both attributed to the lower hardness [35]. Correspondingly, at low input energy (128 J/mm^3), macroscopic defects extremely deteriorated the hardness performance according to low relative porosity. The hardness value of the vertical section was 6.3 % higher than that of the horizontal one. Two reasons may well account for this phenomenon. Firstly, the anisotropic grain morphology was illustrated in **Fig. 5**. Secondly, the tested horizontal section referring to the top region of the SLM parts experienced much more heat loss by convection and radiation but less thermal re-melting than the prior layers. A heterogeneity in hardness was also observed on the vertical section, that the middle region almost surpassed other regions because of enough thermal cycling.

The highest hardness value of the SLM-built copper specimens achieved in this work has a substantial increase of nearly 68.9 % and 5.6 % compared with annealed pure copper (55 HV) and electron beam melting (EBM) prepared ones (88 HV) [36]. The ultrafine microstructure derived from rapid solidification during the SLM process accounts for the superior hardness.

3.2.2 Effect of Anisotropic Microstructure on Electrical and Thermal Conductivities

The electrical conductivity of as-built samples (**Fig. 7a**), from both x- and z-axis orientations increased with the enhancing input energy density and was in proportional to the density. The electrical conductivity was up to 3.1×10^{-1} S/m at a maximum volume energy density of 3000 J/mm^3 , which was equivalent to 53.8 % International Annealed Copper Standard (IACS, the definition of 5.8×10^{-1} S/m as 100 % IACS for electrical conductivity). During the SLM process, the dense grain boundaries derived from the high cooling rate impede the electron movement, which may partly explain the inferior electrical conductivity compared with that of conventional methods. With an input energy above 857 J/mm^3 , the electrical conductivity of EC-z samples showed superior behavior, coinciding with the epitaxial columnar grains aligned parallel to the build direction (similar to the test electron transmit direction). Such columnar grains ~~are mainly~~ attributed to fewer grain boundaries and the vast electrons transported with less scattering, leading to higher electrical conductivity and vice versa along the horizontally oriented one [37]. For input energy below 857 J/mm^3 , the electrical conductivity exhibited an opposite trend because lower density causing severer side-effects (defects and non-melted powder).

Similar to the electrical conductivity, an obvious difference in thermal conductivity was observed for diverse measurement orientations (**Fig. 7b**). For high-density samples ($> 285 \text{ mm}^3/\text{J}$), the thermal conductivity of TC-x samples gradually increased to $214.7 \text{ W m}^{-1}\text{K}^{-1}$, while the TC-z samples were

opposite. During the SLM process, the molten pool size reduced with decreasing input energy and grain growth inclined to follow the radial direction of maximum heat flux, according to the competitive growth mechanism [38]. As a result, grains grew nearly parallel to the x-axis (equal to the test heat flow direction) as the molten pool became narrower and shallower with a decreasing input energy (**Fig. 7c, 7e**). This was beneficial to the thermal conductivity because conductive pathways for electron and phonon transport along the direction of the aligned grains (**Fig. 7d**). However, at the low-density range ($< 285 \text{ mm}^3/\text{J}$), both groups exhibited lower conductivity due to defect barriers. Because the primary mechanisms of electrical and thermal conductivities are the movement of free electrons, the experimental thermal conductivity value was compared with theoretical values to verify Wiedemann–Franz law (Eq. 7 in Supporting Information). A good fit was observed (Fig. 7b) for an optimal 875 J/mm^3 sample, while little discrepancy derived from sample size and microstructure.

3.3 Morphology and Structure of CVD 3DG/Cu Porous Scaffolds

Fine prepared copper porous scaffolds with different porosity were manufactured using optimal processing parameters to leverage the anisotropy in aforementioned performance effectively. Graphene was then *in-situ* grown on the copper template via CVD method. As the growth of graphene on copper substrate mainly involves surface diffusion and nucleation of carbon atoms, obeying a surface adsorption mechanism, the interaction between copper catalyst and graphene film is relatively feeble [39]. According to density functional theory, graphene is weak bonding with copper substrate at a low binding energy of 33 meV per carbon atom, similar to the interplanar binding of graphite (25 meV per carbon atom) [39]. Using carbon isotope labeling during graphene growth on Cu and Ni, Li et al. [40] demonstrated that no metal-carbide compound formed during the growing process. However, considerable advances in

chemical transfer methods (e.g. direct transfer method [23], polymer-free transfer methods [41]) were developed to remove the CVD-grown graphene from the substrate, which also reflected the enough interaction between the graphene and metal. Actually, we have tried to investigate the interface of graphene and metal substrate using SEM, which gave the cross-section morphology not the value of interaction force. The SEM microstructure of the prepared 3DG/Cu porous scaffold revealed good metallurgical bonding of copper powder with a strut diameter of approximately 450 μm (**Fig. 8a**). According to high magnification images of the morphology (**Fig. 8b**), graphene flakes were obvious near the fringe of the scaffold, especially in the defect region. To demonstrate the distribution of graphene on the scaffold substrate, EDS mapping indicated the successful growth of graphene on the copper cellular template with nearly uniform distribution (**Fig. 8c-d**), which confirmed the potential of parameter adjustment in substrate fabrication. A graphene flake was particularly detected at higher magnification (**Fig. 8e-g**). The obtained 3DG/Cu porous hybrid scaffold showed relatively weak luster compared with the initial counterpart (**Fig. 8h**).

Raman spectroscopy was further performed on the 3DG/Cu to obtain additional structural information. The typical G-band ($\sim 1590\text{ cm}^{-1}$) as well as the 2D-band ($\sim 2699\text{ cm}^{-1}$) suggested a narrow thickness distribution around mono to few layers [42] (**Fig. 8i**). Since the D-band ($\sim 1350\text{ cm}^{-1}$) reflects the disordered carbon level in graphene [43], the intensity ratio of D to G bands (ID/IG) was combined to reveal the density of defects. With shorter growth times or lower flow rates, the value of ID/IG increased from 0.71 to 0.93, indicated an increase of defects mainly attributed to totally disordered imperfect edge structures. As a consequence, an optimal growth condition (growth temperature of 1000 $^{\circ}\text{C}$, flow rate of CH_4 in 30 sccm, growth time of 20 min) was used for the 3DG/Cu porous structure.

3.4 Thermal Property and EMI Shielding Effectiveness of 3DG/Cu Porous Scaffolds

Thermal diffusion performance substantially increased upon the addition of graphene on the Cu porous scaffold, up to a 26.8 % increase compared to the initial copper reference sample and a 14.8 % increase to the HT copper samples under the same temperature as the graphene *in-situ* growth (**Fig. 9a**). Since the special one-atom-thick planar structure of graphene can reduce the barriers for phonon transport, the integration of the 3DG/Cu porous scaffold possesses an enhanced conductance. It is also worth noting that the HT copper sample also obtained a rise in thermal performance due to a grain size growth by 1~2 orders of magnitude during heat treatment. In this case, increased grain size reduces grain boundary scattering which restricts the mean free pathway of heat carrier, thus improving the heat transfer. With respect to the good thermal performance, a sophisticated SLM copper air-liquid crossflow heat exchanger (with inner microfluid channel diameter less than 500 μm) and a plate-tube structure was successfully fabricated (**Fig. 9b**), further demonstrating its potential for application in complex heat exchangers with advantages of individualization and cost and time-saving. Given the thermal property stay close to the materials compositions, sample structure, and manufacturing process, we therefore make a rough comparison on the thermal property improvement before and after graphene coating on the metal substrate (**Table 1**). It could be concluded that this work presented a preferable result compared with similar researches. Other extremely high enhancement mainly resulted from the ultralow thermal conductivity base, like Ni or polymer.

To demonstrate the potential of the 3DG/Cu porous scaffold for EMI, the EMI *SE*, which characterizes the capability to attenuate the electromagnetic (EM) radiation, was investigated over the frequency range

of 2–18 GHz (**Fig. 9c**), exhibiting a slight frequency dependence over the frequency range. With *in-situ* grown graphene on copper porous scaffold, the average SE increased from 15.9 to 32.3 dB, with a peak value of 47.8 dB (88.2 % increase), far surpassing the commercially required level for application of ~20 dB. These results further reflected a satisfying interface between the substrate and the graphene. Ji K et al. [44] proved that EMI of the composites increased with increasing pore density. The EMI SE achieved more than 133 % improvement with an increased porosity density (i.e., smaller apertures) from 20 to 110 PPI (pores per inch). Rajeev K's group [45] also agreed with this point by adding cenosphere to enhance the porosity of carbon foam so as to optimize the EMI performance. We found similar result by increasing porosity density from 17 to 26 PPI (**Fig. 9c insert**) and obtained a 105 % enhancement in EMI SE . In other words, the EMI shielding properties can be adjusted by scaffold porosity with the aid of lightweight design from SLM. The 3DG/Cu porous structure in 26 PPI exhibited an average EMI SE of 32.3 dB, corresponding to 99.9 % blocking of the EMI waves. The same level of shielding in graphene foam was achieved using a 60 mm thick foam (30 times thicker than our current scaffold) [46]. The EMI shielding performances of 3DG/Cu with similar graphene-based materials are also listed in **Tables 1**. It could be concluded that the EMI SE of the 3DG/Cu in our work is comparable or even higher than those of other 3D graphene-based materials, convincing a relatively promising application potential.

The main mechanisms of EMI consist of reflection (SE_r), absorption (SE_a) and multiple reflections of electromagnetic (EM) waves [47], which are mainly bound up with mobile charge carriers, electric or magnetic dipoles, and interfaces of shielding materials, respectively [48]. Researchers [49] have found that metal like copper with high electrical conductivity, mainly plays a role in reflecting electromagnetic waves, which is attribute to the interaction with free electrons or holes. The graphene is expected to show

an absorption dominant EM wave loss resulted from the interaction of the electromagnetic field and electric dipoles [50]. Recent researches on EMI have been exponentially increased. The most commonly used method is to form a conductive network within weak or non-conductive matrix by mixed with metal fillers, such as Cu [51]. For an achievement of better absorption-dominant shielding performance, graphene was generally incorporated into epoxy [52] or SiO₂ [53]. We found that this 3DG/Cu porous scaffold showed an outstanding performance due to the synergistic shielding mechanisms with a significant increase for both SE_r and SE_a , as schematically shown in **Fig. 9e**. When the microwaves were incident on the surface of the 3DG/Cu porous scaffold, some waves were immediately reflected into the environment, while the remaining waves penetrated deep inside the porous scaffold. Simultaneously, the bilayer structure of the 3DG/Cu composites provided increased number of interfaces for reflections and absorptions of microwaves owing to the impedance mismatch between layers. The impinging EM waves firstly encountered the graphene layer with the highest charge carrier mobility interaction with the EM waves, resulting in an enhancement of the ohmic loss accounting for the SE_r . On the other hand, the graphene additive alleviated the mismatch impedance between air and copper scaffold, which was greatly beneficial to the EM wave absorption into the scaffold, and as a result, attenuated EM energies by energy dissipation or energy consuming responses. The aforementioned intensive thermal diffusion which helped to convert microwave energy into Joule heating [54]. It is worth to note that the graphene film concurrently enables the microwaves to penetrate the metallic layer longitudinally for further reflection effects. Moreover, the large surface area and porosity of the interconnected graphene network on the gyroid cellular substrate, one of triple periodic minimal surfaces with curved surfaces, facilitated multiple reflections and scattering of EM waves inside the material, thus further promoting the dissipation of EM

waves. The scattering of the incident wave especially appeared when it encountered a curved surface [44]. This successive scattering behavior in all directions within the 3D interconnected skeleton highly reduced the radiation intensity until most EM waves were absorbed by the materials. Interestingly, the existing of CVD graphene defects as revealed by Raman spectroscopy and the formation of imperfect substrates as revealed in Section 3.3 also functioned as scattering centers contributing to the enhanced losses caused by dielectric relaxation, thereby realizing a higher shielding performance [55]. It is believed that the EM waves will be trapped by the defect structures, which act as scattering centers to facilitate polarization loss. On the whole, the porous structure of the 3DG/Cu composites can attenuate the radiation by reflection, scattering, and absorption between the graphene film and copper skeleton. The multiple dissipation mechanisms prevented the escape of the microwaves from the scaffold before being absorbed and transformed into heat or other energy.

4. Conclusions

A tunable 3DG/Cu porous scaffold was successfully fabricated with homogeneously *in-situ* deposition of graphene layer via CVD method. The anisotropic microstructure and heterogeneous composition were optimized for the copper porous scaffold fabrication. With the accurate design and regulation from composition to structure, the 3DG/Cu structure resulted in a remarkable value % enhancement in EMI *SE* from an average 15.9 (for reference sample) to 32.3 dB, exhibiting a peak value of 47.8 dB (88.2 % increase), as well as a 26.8 % increase in the thermal diffusion. The hybrid 3DG/Cu demonstrated extraordinarily synergetic effects in reflection, absorption and multiple reflection shielding mechanisms. These major improvements in EMI and thermal conductivity make the current 3DG/Cu porous scaffolds a promising alternative for applications in EMI shielding and thermal management.

Competing Interests

The authors declare that there is no conflict of interest regarding the publication of this paper.

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Figure captions

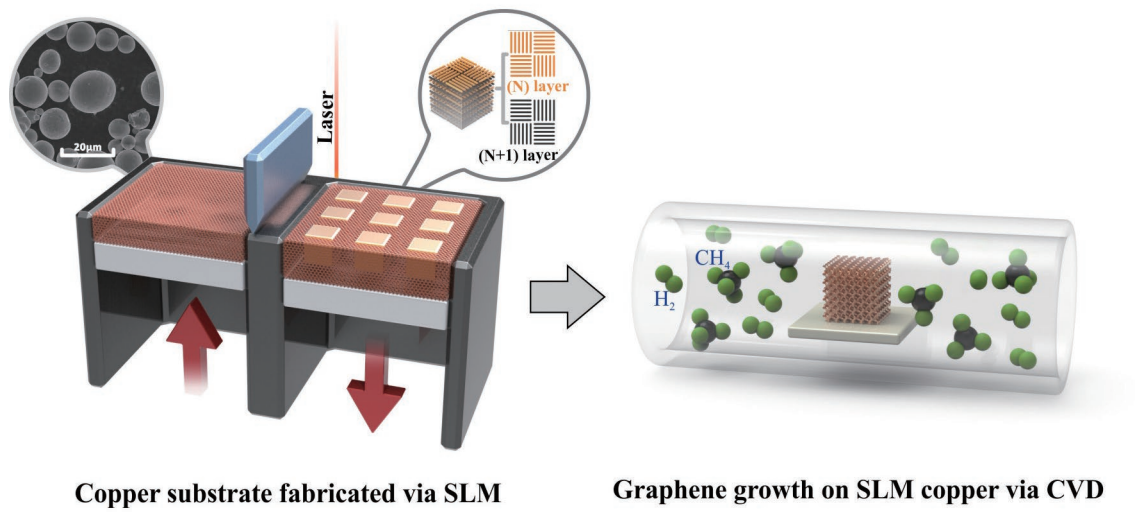


Fig. 1 Illustration of the 3DG/Cu porous structure fabrication process: copper scaffold fabricated via SLM (left) and in-situ graphene growth on the copper scaffold via CVD (right).

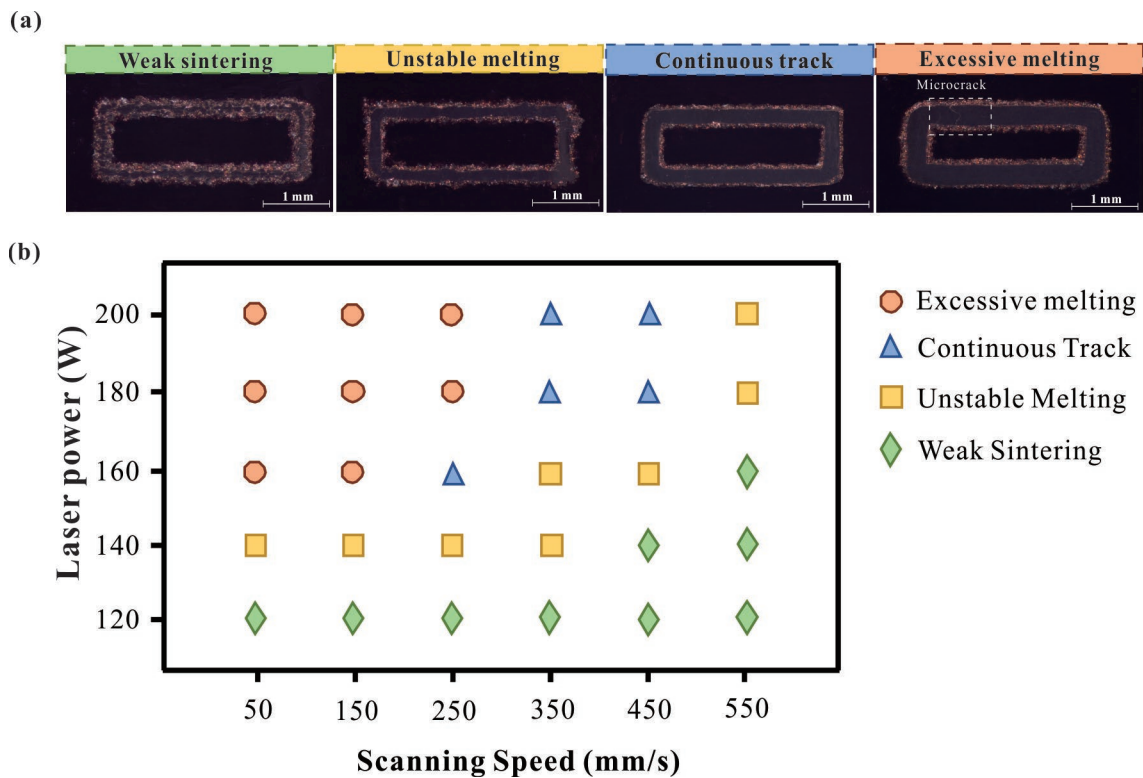


Fig. 2 (a) Typical track types of a weak sintering zone, unstable melting zone, continuous track zone, and excessive melting zone, respectively; (b) processing window of laser power and scanning speed.

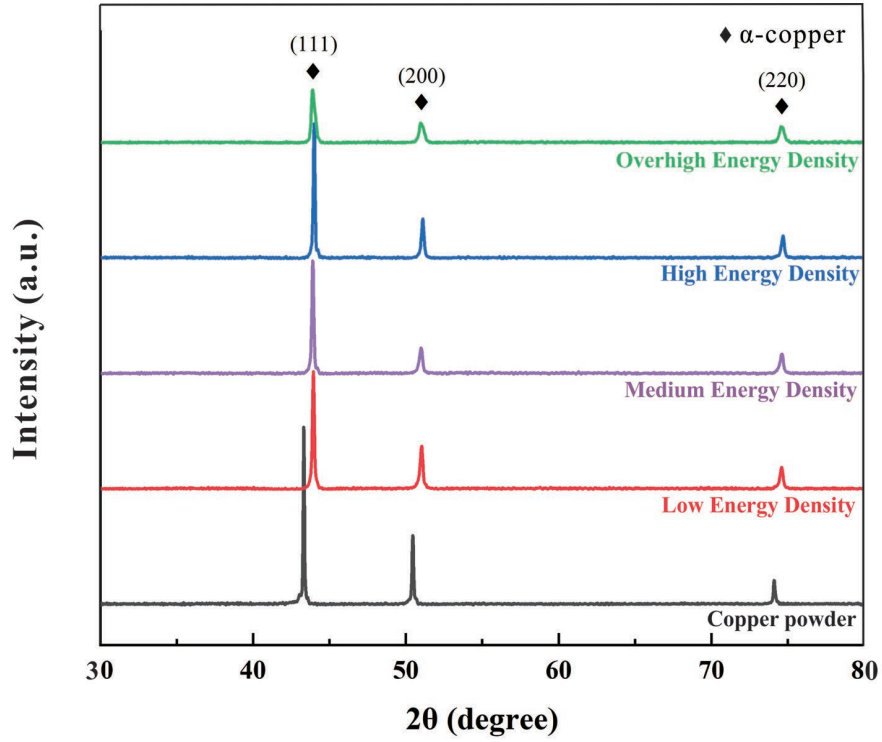


Fig. 3 XRD patterns of the starting copper powder and as-built copper specimens.

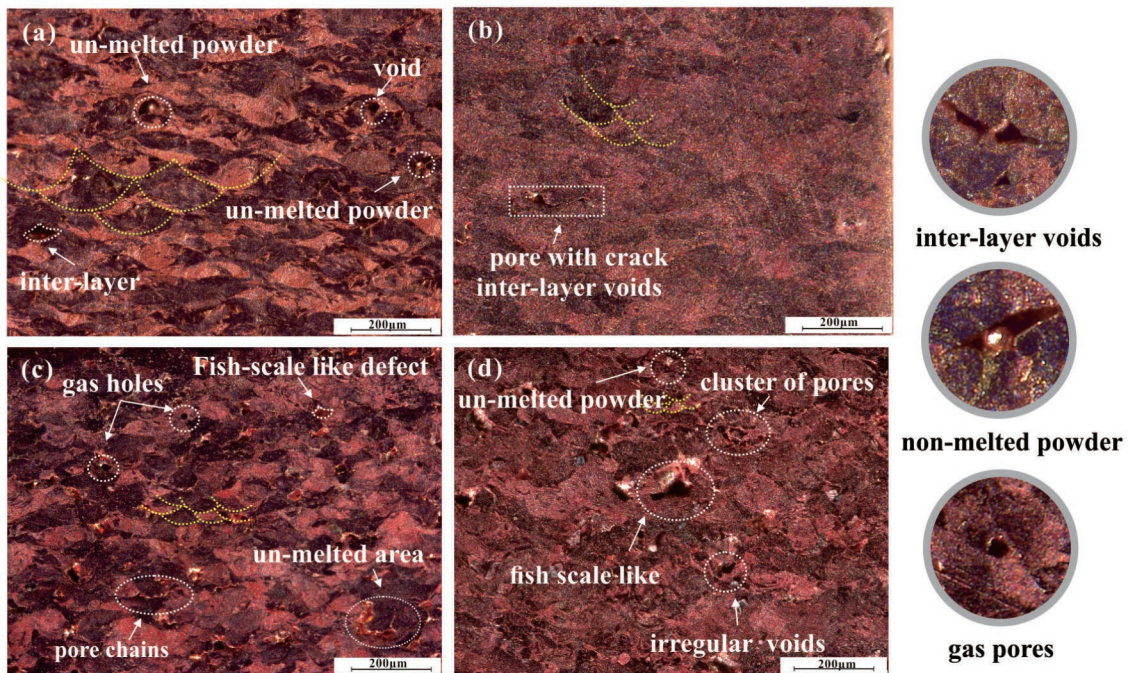


Fig. 4 Optical micrographs of typical morphology of samples fabricated by various input energy in vertical direction: (a) excessive (3000 J/mm^3), (b) high (857 J/mm^3), (c) medium (285 J/mm^3), (d) low energy (128 J/mm^3), respectively.

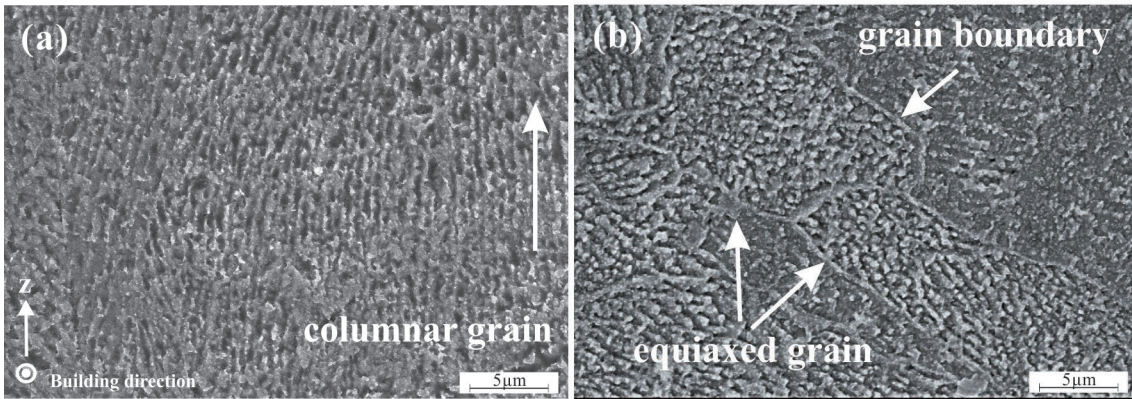


Fig. 5 SEM images of typical microstructures on the etched vertical and horizontal planes of as-built parts.

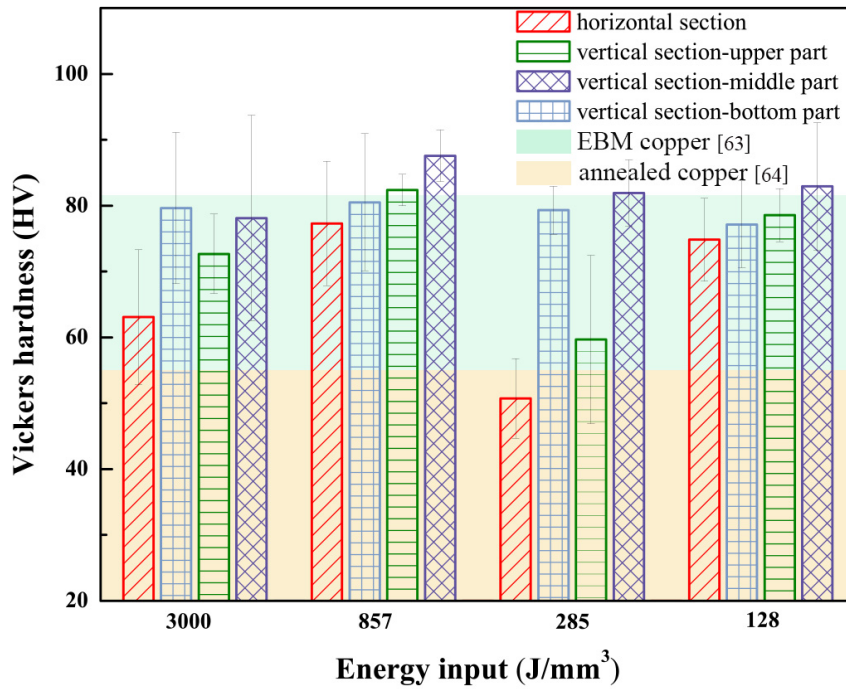


Fig. 6 Vickers hardness of SLM-built samples among various input energies compared with EBM [63] and anneal copper [64].

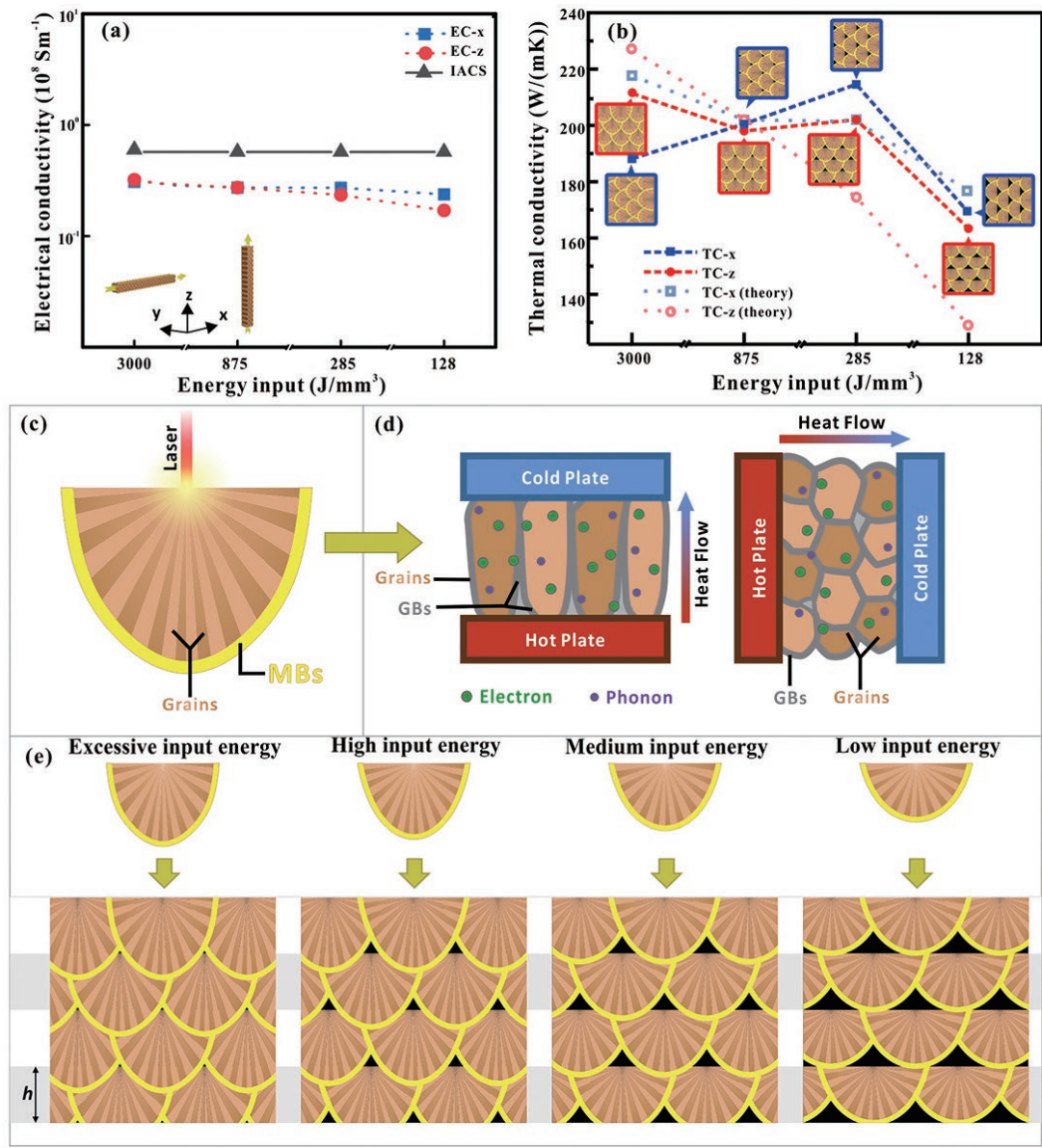


Fig. 7 (a) Electrical and (b) thermal conductivity for four types of input energy; (c) schematic of molten pool; (d) schematic of thermal conductivity measurement; (e) schematic of molten pool formation under different input energy. (Error bars are omitted for better reading).

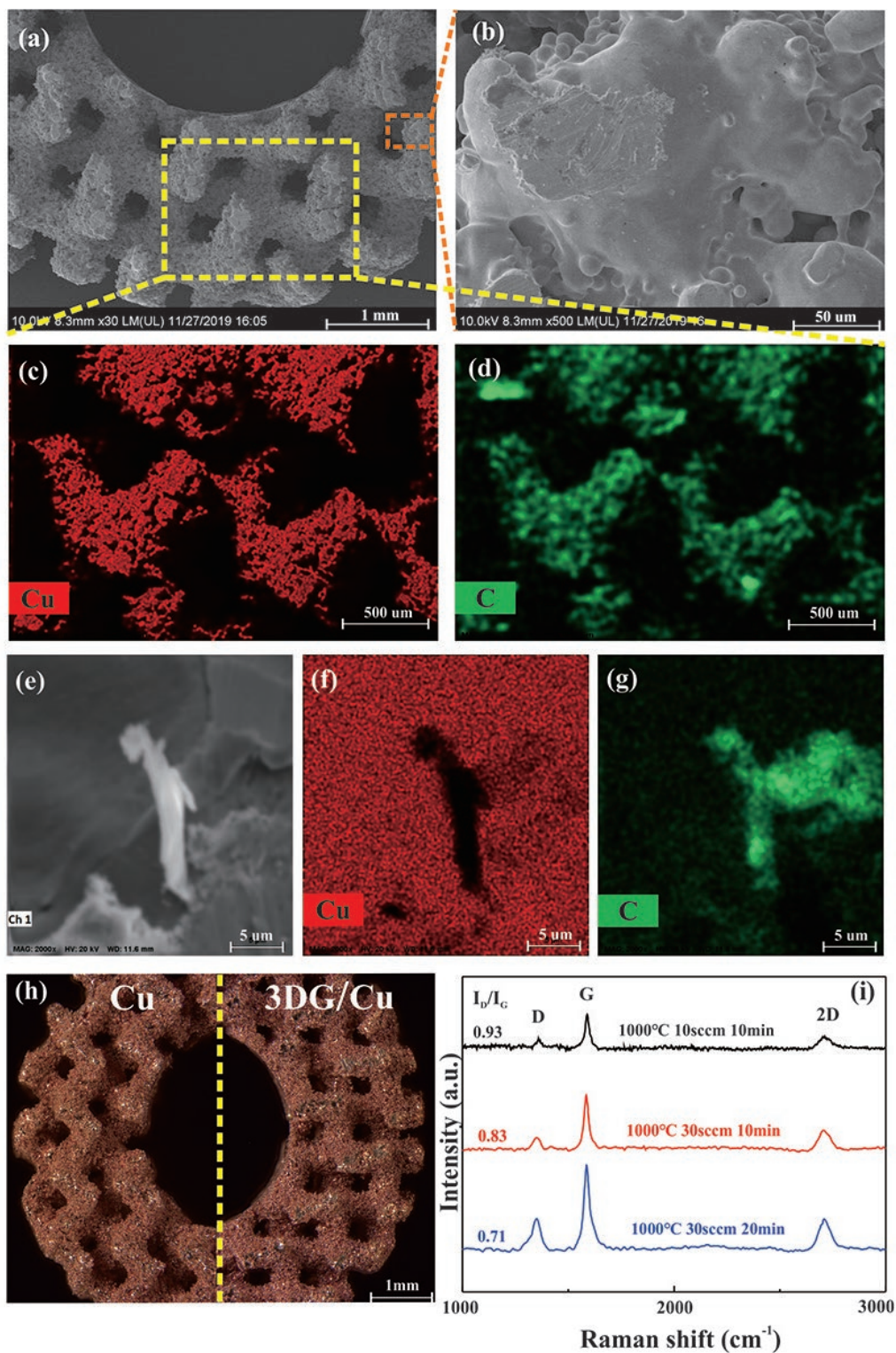


Fig. 8 (a-b) SEM images of 3DG/Cu porous scaffold under different magnifications; EDS mapping image of (c) Cu and (d) C; (e) local magnification of SEM image, corresponding EDS mapping image of (f) Cu and (g) C; (h) comparison before and after graphene growth of OM; (i) Raman spectra of graphene on copper scaffold under different growth conditions

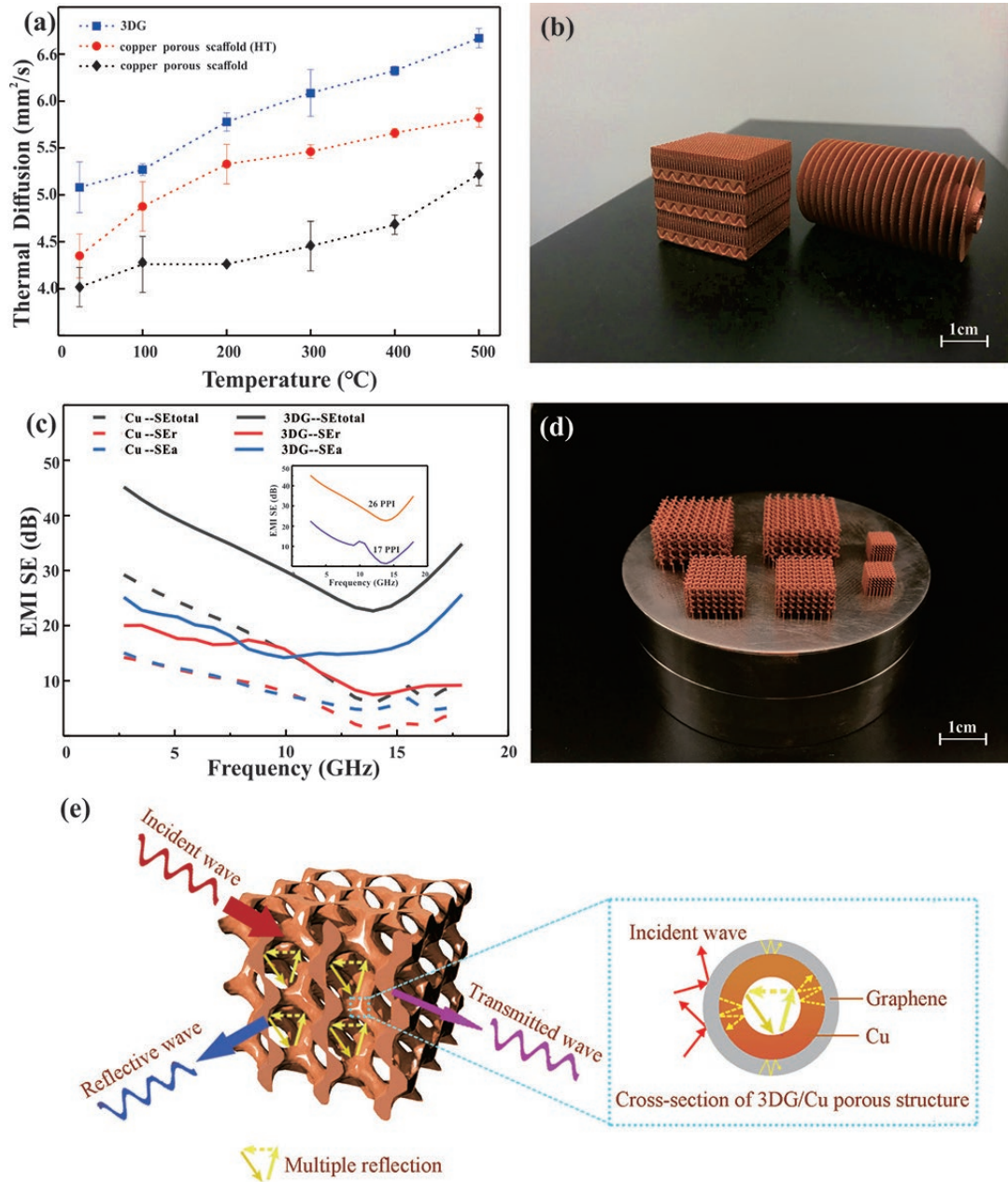


Fig. 9 Performance of 3DG/Cu porous scaffold: (a) thermal diffusion; (b) SLM copper air-liquid crossflow heat exchanger (with micron-scale inner microfluidic channel) and a plate-tube structure for thermal management; (c) EMI SE; (d) Copper scaffold with different porosity; (e) Schematic of 3DG/Cu on EMI.

Table caption

Table 1 Comparison of literature reported graphene-based porous materials with similar composition or structure on EMI shielding performance and thermal performance improvement. (PMMA: poly (methyl methacrylate), PS: polystyrene)

Coating materials	Substrate	Method	Maximum shielding efficiency (dB)	Improvement of thermal property (%)	Ref
Graphene aerogels	Graphite texture	Immersion + freeze dried + anneal + chemical methods	37	-	[50]
Graphene	PS	high-pressure compression molding + salt-leaching	29.3	-	[56]
Graphene	PMMA	Solution blending + melt compounding + batch foaming	19	-	[57]
Cu/Graphene/Cu	Al	Surface modification + electrochemical plating	-	8.5	[58]
Graphene	Ni	Foaming + CVD	-	554	[59]
Graphene	Cu-Ni	Electroless plating + electrophoretic deposition	20	-	[60]
Graphene	Cu	Powder sintering + CVD	-	2.4	[61]
Graphene aerogels	Cu	Freeze-drying + thermal annealing	47	6.3	[62]
Graphene	Cu	CVD + SLM	47.8	27	This work